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OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS					
Examiner Initials'	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc., date, page(8), volume-issue number(3), publisher, city and/or country where published.			
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw time through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.					

'Unique citation designation number. ¹ See attached Kinds of U.S. Patent Documents. ³ Einter Office that issued the document, by the two-letter code (WIPO StandardST.3). ¹ For Japanese patent documents, the indication of the year of the reign of the Emperor must proceed the serial number of the petent document. ¹ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁴ Applicant is to place a check mark here if English Language Translation is attached.